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Development of a Novel Method for the Preparation of Dithioacetal in the Presence of Titanium(IV) Chloride/Zinc in Dimethoxymethane

Ji-Hyun Lee, Hyung Jae Jeong, Chung Keun Jin, Sang Hun Jang, Min Kyu Kim, Yong-Jin Yoon,^{†,*} and Sang-Gyeong Lee^{*}

Department of Chemistry and Research Institute of Life Science, GyeongSang National University, Jinju 660-701, Korea *E-mail: leesang@nongae.gsnu.ac.kr

[†]Department of Chemistry and Research Institute of Basic Science, GyeongSang National University, Jinju 660-701, Korea Received October 25, 2004

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Organosulfur compounds are important intermediates in organic synthesis. Since the pioneering report by Corey and Seebach,¹ sulfur-stabilized carbanion has played an important role in organic synthesis. Recently, a new reaction method was developed that consists of a reductive lithiation of alkyl or arylthioesters² and ring closing metathesis of titanium carbene complex prepared from thioacetals.³ In general, bis(methylthio)methane is used for the synthesis of ketene thioacetal⁴ by the reaction with aldehyde or ketone, and bis(phenylthio)methane is used for the synthesis of alkenes,⁵ ketones,⁶ allyic alchols⁷ and 1,3-dienes.⁸ In these reactions, only a few reagents, such as bis(methylthio)methane and bis(phenylthio)methane, are used presumably because the reagents are commercially available and can be prepared under limited conditions. In spite of the importance of dithioacetals or sulfur-stabilized carbanions in organic synthetic chemistry, only a few synthetic methods were known.

A general method for the preparation of bis(alkyl or arylthio)methanes is shown in Eq. 1. Sodium thioalkoxide or thiophenoxide reacts with diiodomethane in an appropriate solvent.^{6b,9}

$$RS^{-}Na^{+} + CH_{2}I_{2} \xrightarrow{\text{Solvent}} RS\text{-}CH_{2}\text{-}SR \quad (1)$$

R = Methyl, Phenyl

For the preparation of dithioacetals by Eq. 1, the starting materials (alkyl or arylthiol) without a metal sensitive functional groups, such as hydroxy, carboxylic acid, and amino group, should be used. Therefore, only a few kinds of bis(alkyl or arylthio)methane can be prepared, and the poor supply of starting materials leads to the limited application in organic synthesis.

From this point of view, we need to develop a new method for the preparation of various dithioacetals. The preparation of this new class of various dithioacetals offers rich potential in synthetic organic chemistry. For example, the formation of the S-CH₂-S bond between two N-CBZ-protected cysteins, which are of great interest for their biological activity, has been the object of synthesis of the methylenedithioacetal analogue of enkephalin,¹⁰ and intensive studies have been focused on the diastereoselective reactions employing dithioacetal as chiral auxiliaries.¹¹

Results and Discussion

Recently, we developed titanium-mediated protection of heterocyclic thiols *via* the formation of MOM-, EOM- ethers without using a carcinogenic reagent, such as chloromethyl methyl ether.¹² In continued research on the reaction between thiols and dimethoxymethane (DMM) or diethoxymethane (DEM), we found that the different products are obtained according to the nature of thiols. In the case of the reaction between heterocyclic thiols and DMM or DEM, only the corresponding MOM protected thioethers were obtained. The reaction between aromatic- and aliphatic thiols and DMM or DEM, however, gave the corresponding dithioacetal compounds (Eq. 2).

$$RSH + TiCl_{4} + Zn(dust) - \begin{bmatrix} DMM \\ or DEM \\ DMM \\ or DEM \end{bmatrix} RS-CH_{2}-OCH_{3} \\ R = Heterocycles \\ RS-CH_{2}-SR \\ R = Aromatics \\ or aliphatics \end{bmatrix} (2)$$

The results are summarized in Table 1. The starting thiols containing ether (entry 3), ester (entry 2, 4, 6) and amino (entry 6) functional group were reacted under our conditions to give the corresponding dithioacetals in moderate yields. N-CBZ-protected cystein 6 efficiently, providing the corresponding dithioacetal 18 in 76% yield (Entry 6). When dithiols, such as 7, 8 and 9 reacted with DMM or DEM in the same conditions, cyclic dithioacetals 20, 21 and 22 were obtained in good yields (Entry 7, 8 and 9). The commercial products 20 and 21 can be easily prepared in laboratory by using our simple method. Particularly, we obtained the macrocyclic compound 22 from the starting material 9. We investigated the methylene insertion reaction between thiol and oxygen atom for 10 (Entry 10). Our results show that the methylene insertion reaction between thiol and oxygen afforded only the corresponding macrocycle 23 in good vields (entry 8, 9).

The analytical data (¹H and ¹³C-NMR, mp) of the known products (compound **11** and **19**) were matched with those of authentic samples and the new products were characterized

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Table 1. The Yield of RS-CH2-SR Obtained From The Reaction of R-SH and TiCl4/Zn in DMM
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Entry	Thiol		Product		Yield (%)
1	SH	(1)	C S S	(11)	76
2	SH OMe	(2)		(12)	78
3	SH	(3)	OMe OMe	(13)	67
			SMOM	(14)	6
4	MeO SH	(4)	MeO MeO S MeO S	(15)	62
			Meo	(16)	21
5	SH	(5)	∽∽∽s∽s∽∽∽∕	(17)	70
6	CO ₂ Me CBZHN [\] SH	(6)	CO ₂ Me CO ₂ Me CBZHN S S NHCBZ	(18)	76
7	HS	(7)	S S	(19)	84
8	HS SH	(8)	os	(20)	92
9	HS~~O~~SH	(9)		(21)	68
				(22)	15
10	SH	(10)	-Vs70	(23)	87

1) All reaction carried out under the same conditions. 2) Yield was calculated after purification.

by ¹H and ¹³C-NMR spectroscopy and mass spectrometry. Under the conditions described above, it was possible for TiCl₄ to serve as a Lewis acid for the methylene insertion reaction of thiols. To test this possibility, reactions of thiols

with dimethoxymethane in the presence of 4 equivalents of Lewis acids, such as TiCl₄, SnCl₄ and AlCl₃, were investigated. Under these conditions, the reactions resulted in less than 30% conversion of thiol to dithioactal derivatives in

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3hr. The rate order to synthesize dithioacetals in the presence of Lewis acids was $TiCl_4/Zn$ [Ti] > $AlCl_3$ > $TiCl_4$ > $SnCl_4$. Therefore, methylene insertion reaction under the $TiCl_4$ / Zn system appeared not simply as a $TiCl_4$ catalyzed dithioacetal formation process but proceeded by another mechanism as a single electron transfer.¹³

We have developed a new synthetic method for the preparation of dithioacetal, which employs TiCl₄/Zn in DMM. Dithioacetals containing versatile functional groups, such as ether, ester, and amino group can be obtained cleanly. Investigations on applying this thioacetals and the mechanistic aspects are currently underway and will be reported in due course.

Experimental Section

General remarks. All non-aqueous reactions were carried out under nitrogen. THF was distilled from Na/ benzophenone; methanol was distilled from Mg; methylene chloride was distilled from CaH₂. Melting points were determined by an electrothermal digital melting point apparatus IA 9000 and uncorrected. NMR spectra were measured on a Bruker ARX-300 (500 MHz) spectrometer in CDCl3 solution used as an internal standard unless otherwise noted (value in ppm); coupling constants are reported in Hz. IR spectra were taken on a Hitachi 270-50FT/IR spectrophotometer (v_{max} , cm⁻¹). The elemental analysis was performed with LECO Micro Carbon Hydrogen Determinator (CHN-800). Mass spectra were obtained by using JEOL JMS-700 spectrophotometer. TLC was run on Merck precoated silicalgel plates. Merck silicagel 60 (230-400 mesh) was used for column chromatography.

A typical procedure for preparation of dithioacetals by thiols with TiCl₄/Zn system. To a pre-stirred (1 hr, 0 °C) mixture of TiCl₄ and zinc dust in a 1 : 2 molar equivalent ratio in 30 mL of dimethoxymethane was added the thiol (30 mmol). The resulting solution was stirred for 2hr at 0 °C to 25 °C, poured into water (50 mL), stirred for 1hr at rt, and extracted with EtOAc (30 mL × 3). The extract was washed with water and brine, dried over MgSO₄, and concentrated *in vacuo*. Silicagel column chromatography (*n*-Hexane/EtOAc = 10/1, v/v) of the residue provided the pure methylene inserted products between alkyl or arylthio moiety (see Table 1).

Bis(2-methoxy carbonyl mercaptophenyl)methane (12): IR (KBr disk) 3010, 2940, 2910, 1700, 1560, 1430, 1250, 1140; ¹H NMR (500 MHz, CDCl₃) δ 7.97-7.95 (dd, *J* = 7.81, 1.46 Hz, 1H), 7.54-7.52 (m, 1H), 7.50-7.46 (m, 1H), 7.23-7.20 (m, 1H), 4.41 (s, 1H, -SCH), 3.90 (s, 3H, -OCH₃); ¹³C NMR (125 MHz, CDCl₃) δ 166.8, 140.0, 132.5, 131.2, 128.4, 126.8, 124.8, 52.1, 35.7; EI-MS m/z (real intensity) 348 (M⁺, 23), 181 (100), 151 (83), 136 (27), 121 (44), 108 (39), 77 (31).

Bis(2-methoxy mercaptophenyl)methane (13): IR (KRS-5 disk) 3050, 2990, 2930, 2830, 1580, 1470, 1240, 1020, 740; ¹H NMR (500 MHz, CDCl₃) δ 7.42-7.40 (dd, J = 7.62, 1.64 Hz, 1H), 7.25-7.21 (m, 1H), 6.93-6.90 (m, 1H),

6.85-6.83 (dd, J = 8.20, 1.0 Hz, 1H), 4.35 (s, 1H), 3.87 (s, 3H, -OCH₃); ¹³C NMR (125 MHz, CDCl₃) δ 132.0, 128.5, 121.0, 110.7, 55.7, 36.5; EI-MS m/z (real intensity) 292 (M⁺, 35), 153 (100), 138 (67), 109 (12), 84 (14), 77 (14), 65 (8), 51 (7).

Methoxy S-methoxymethyl 2-mercaptobenzene (14): IR (KRS-5 disk) 3100, 2950, 2900, 1600, 1500, 1450, 1250, 1200; ¹H NMR (500 MHz, CDCl₃) δ 7.53-7.51 (dd, 1H, J = 1.63 Hz, J = 7.70 Hz), 7.23-7.20 (m, 1H), 6.94-6.92 (m, 1H), 6.87-6.85 (dd, 1H, J = 0.96 Hz, J = 8.21 Hz), 4.97 (s, 2H), 3.88 (s, 3H), 3.42 (s, 3H); ¹³C NMR (125 MHz, CDCl₃) δ 157.5, 131.1, 127.9, 123.6, 121.3, 110.7, 76.0, 56.1, 55.8. EI-MS *m/z* (real intensity) 184 (M⁺, 100), 168 (8), 154 (38), 139 (17), 109 (17), 77 (15).

Bis(methyl 3-mercaptopropionate)methane (15): IR (KRS-5 disk) 2950, 1740, 1440, 1360, 1250, 1040; ¹H NMR (500 MHz, CDCl₃) δ 3.70 (s, 4H, -OCH₃ and -SCH), 2.90 (t, J = 7.3 Hz, 2H), 2.37 (t, J = 7.3 Hz, 2H); ¹³C NMR (125 MHz, CDCl₃) δ 26.1, 34.6, 36.0, 52.2, 172.6; EI-MS *m/z* (real intensity) 252 (M⁺, 25), 165 (8), 133 (100), 119 (11), 87 (12), 55 (56).

S-Methoxymethyl methyl 3-mercaptopropionate (16): IR (KRS-5 disk) 2950, 2820, 1740, 1430, 1360, 1180, 1080; ¹H NMR (500 MHz, CDCl₃) δ 4.64 (s, 2H, -SCH₂), 3.70 (s, 3H, -OCH₃), 3.34 (s, 3H, -OCH₃), 2.86 (t, *J* = 7.3 Hz, 2H), 2.67 (t, *J* = 7.3 Hz, 2H); ¹³C NMR (125 MHz, CDCl₃) δ 172.4, 75.7, 55.7, 51.8, 35.2, 26.2; EI-MS *m/z* (real intensity) 164 (M⁺, 6), 149 (100), 132 (33), 104 (15), 84 (35), 77 (21), 55 (25).

Bis(pentylthio)methane (17): IR (KRS-5 disk) 2930, 2960, 2860, 1460, 1380, 1200; ¹H NMR (300 MHz, CDCl₃) δ 3.66 (s, 2H), 2.62 (t, J = 7.4 Hz, 4H), 1.61-1.57 (m, 4H), 1.39-1.30 (m, 4H), 0.90 (t, J = 7.0 Hz, 6H); ¹³C NMR (75 MHz, CDCl₃) δ 35.4, 31.1, 30.8, 28.8, 22.3, 14.0; EI-MS m/z (real intensity) 220 (M⁺, 100) 117 (40), 84 (44), 69 (41), 61 (39).

Bis(2-benzyloxycarbonylamino methyl 3-mercaptopropionate)methane (18): IR (KRS-5 disk) 3330, 3030, 2950, 1720, 1520, 1340, 1210, 1050; ¹H NMR (500 MHz, CDCl₃) δ 7.34-7.25 (m, 5H), 5.65 (s, 1H, -NH), 5.11 (s, 2H, -CH₂Ph), 4.60 (d, J = 5.25 Hz, 1H), 3.74 (s, 3H, -OMe), 3.62 (s, 1H), 3.13-3.09 (m, 1H), 3.4-3.0 (m, 1H); ¹³C NMR (125 MHz, CDCl₃) δ 171.1, 155.7, 136.1, 128.5, 128.2, 128.1, 67.2, 53.4, 52.7, 36.5, 33.2; EI-MS m/z (real intensity) 550 (M⁺, 78), 236 (6), 207 (3), 162 (10), 146 (56), 91 (100), 79 (26), 59 (7).

[1,4,6]Oxadithiocane (20): IR (KRS-5 disk) 2910, 2850, 1460, 1400, 1290, 1210, 1100; ¹H NMR (500 MHz, CDCl₃) δ 4.15 (s, 2H, -SCH₂), 3.89 (t, J = 4.79 Hz, 4H), 2.82 (t, J = 4.90 Hz, 4H); ¹³C NMR (125 MHz, CDCl₃) δ 73.2, 38.7, 31.2; EI-MS m/z (real intensity) 150 (M⁺, 53), 136 (7), 103 (5), 84 (100), 78 (7), 61 (34), 51 (38).

1,9,12,20-Tetraoxa-4,6,15,17-tetrathiacyclodocosane (21): IR (KRS-5 disk) 2950, 2930, 1330, 1290, 1100; ¹H NMR (500 MHz, CDCl₃) δ 3.94 (s, 1H), 3.74 (t, *J* = 6.03 Hz, 2H), 3.62 (s, 2H), 2.85 (t, *J* = 6.04 Hz, 2H); ¹³C NMR (125 MHz, CDCl₃) δ 71.4, 70.6, 36.7, 30.4; EI-MS m/z (real intensity) 388 (M⁺, 25), 329 (16), 315 (35), 207 (39), 194 (20), 147 (26), 103 (37), 75 (100), 61 (100), 60 (67).

1,9-Dioxa-4,6-dithiacycloundecane (22): IR (KRS-5 disk) 2960, 2910, 1120, 1100, 1050; ¹H NMR (500 MHz, CDCl₃) δ 4.07 (s, 1H), 3.83 (t, J = 5.83 Hz, 2H), 3.68 (s, 2H), 2.83 (t, J = 5.83 Hz, 2H); ¹³C NMR (125 MHz, CDCl₃) δ 73.6, 71.8, 36.3, 31.2; EI-MS *m/z* (real intensity) 194 (M⁺, 56), 149 (4), 135 (11), 117 (31), 103 (21), 91 (18), 75 (42), 61 (100), 60 (62).

11-Dimethyl-5-oxa-3-thiatricyclo[6.2.1.0^{1,6}]**undecane** (23): IR (KRS-5 disk) 2950, 2880, 1450, 1370, 1260, 1070, 970; ¹H NMR (500 MHz, CDCl₃) δ 4.78-4.75 (dd, *J* = 11.0, 2.2 Hz, 1H), 4.72 (d, *J* = 10.9 Hz, 1H), 3.52-3.50 (dd, *J* = 8.0, 3.2 Hz, 1H), 3.05 (d, *J* = 14.1 Hz, 1H), 2.72-2.68 (dd, *J* = 14.1, 2.2 Hz, 1H), 1.87-1.83 (m, 1H), 1.72-1.67 (m, 1H), 1.46-1.43 (m, 1H), 1.35 (s, 3H), 1.03-1.01 (m, 1H), 0.95-0.90 (m, 1H), 0.91 (s, 3H); ¹³C NMR (125 MHz, CDCl₃) δ 84.6, 77.3, 77.1, 76.8, 69.38, 46.7, 45.5, 43.1, 37.7, 34.9, 28.1, 27.3, 23.4, 20.4; EI-MS *m/z* (real intensity) 198 (M⁺, 78), 150 (25), 135 (28), 121 (22), 108 (100), 93 (72), 67 (37), 55 (38).

References

1. Corey, E. J.; Seebach, D. Angew. Chem., Int. Ed. Engl. 1965, 4,

1075.

- (a) Screttas, C. G.; Micha-Screttas, M. J. Org. Chem. 1978, 43, 1064. (b) Screttas, C. G.; Micha-Screttas, M. J. Org. Chem. 1979, 44, 713. (c) Cohen, T.; Bhupathy, M. Acc. Chem. Res. 1989, 22, 152.
- 3. Fujiwara, T.; Kato, Y.; Takada, T. Tetrahedron 2000, 56, 4859.
- (a) Seebach, D.; Kolb, M.; Gröbel, B.-T. *Ber.* **1973**, *106*, 2277. (b) Seebach, D.; Bürstinghaus, R. *Angew. Chem. Int. Ed.* **1975**, *14*, 57. (c) Seebach, D.; Bürstinghaus, R. *Synthesis* **1975**, 461.
- 5. Ager, D. J. Tetrahedron Lett. 1981, 22, 2932.
- (a) Ager, D. J. Tetrahedron Lett. **1980**, 21, 4763. (b) Corey, E. J.; Seebach, D. J. Org. Chem. **1966**, 31, 4097. (c) Blatcher, P.; Grayson, J. I.; Warren, S. J. Chem. Soc. Chem. Commun. **1976**, 547.
- 7. Foubelo, F.; Gutiérrez, A.; Yus, M. Tetrahedron Lett. 1999, 40, 8177.
- Horikawa, Y.; Watanabe, M.; Fujiwara, T.; Takeda, T. J. Am. Chem. Soc. 1997, 119, 1127.
- (a) Mosberg, H. I.; Omnaas, J. R. J. Am. Chem. Soc. 1985, 107, 2986. (b) Mosberg, H. I.; Omnaas, J. R.; Goldstein, A. Mol. Pharmacol. 1987, 31, 599.
- 10. Delogu, G.; Lucchi, O. D.; Maglioli, P. J. Org. Chem. 1991, 60, 4467.
- (a) Ueki, M.; Shinozaki, K. *Bull. Chem. Soc. Jpn.* **1984**, *57*, 2156.
 (b) Ueki, M.; Ikeo, T.; Hokari, K.; Nakamura, K.; Saeki, A.; Komatsu, H. *Bull. Chem. Soc. Jpn.* **1999**, *72*, 829.
- Jeong, H. J.; Yoon, E. Y.; Kim, M. K.; Lee, J. H.; Yoon, Y. J.; Lee, S. G. Bull. Korean Chem. Soc. 2003, 24, 1689.
- Fürstner, A.; Hupperts, A.; Ptock, A.; Janssen, E. J. Org. Chem. 1994, 59, 5215.